

NS6130-10-1278

TRIPHENYLAMINE

Sputtering Target

Quick Facts

Product	:	Triphenylamine Sputtering Target
Stock No	:	NS6130-10-1278
CAS	:	124729-98-2
Molecular Formula	:	C ₅₇ H ₄₈ N ₄
Form	:	Solid

Technical Specification

Diameter	Thickness
2"	3mm

Triphenylamine sputtering targets are used in a wide range of applications in the field of electronics and optoelectronics. Triphenylamine is used as a charge-transporting material in OFETs. Triphenylamine thin films deposited using sputtering targets can be used to fabricate high-performance OFETs.

Triphenylamine thin films deposited using sputtering targets can be used to fabricate sensors for the detection of gases and other substances. Triphenylamine thin films deposited using sputtering targets can be used to fabricate high-efficiency OPVs.



* This image is for graphic purposes only and does not represent the actual product.

